

WHO'S WHO | in Intellectual Property Law

RONALD J. BARON

Hoffmann & Baron, LLP



Ronald J. Baron is managing partner at Hoffmann & Baron, LLP in Syosset, NY.

Baron is experienced in patent and trademark litigation at the trial and appellate levels, as well as preparation and prosecution of patent and trademark applications.

"Faced with the many problems existing in the economic environment, the President and the executive branch must take many measures that will improve the financial security for millions of workers in the short and long term," Baron said.

"Certainly not the least of the measures that can have a positive influence on the American financial scene is the creation of an accessible and reliable intellectual property law

system," Baron said. "This means that entrepreneurs of every stripe and size can obtain meaningful intellectual property rights and expect to have those rights enforced. This will require a serious and long-term commitment from all three branches of our federal government, the most important of which is the executive branch."

"The new administration can seek to avoid the pernicious effects of fee diversion, which has plagued the running of the Patent Office in previous administrations," he said. "Specifically, the fees paid by applicants to obtain an examination and issuance of US patents should be available to attract and retain high quality patent examiners and competent administrators, not to mention support the extensive computer infrastructure required to sustain such an extensive system."

"Past administrations have diverted a percentage of these fees to use in other areas of the government," he noted.

"Consequently, the Patent Office struggles to sustain itself and attract competent new personnel while maintaining an acceptable level of experienced examiners and administrators," Baron said.

"Care should also be given to ensure that compensation and workload reforms are put into place in order to attract and retain a high level of examiners and administrators in the US Patent Office," Baron noted. "Furthermore, the new President should ensure that recommendations for appointment of judges include attorneys who have a technical background and an expertise in the area of the US Patent Law."

Baron earned a juris doctorate from St. John's University School of Law and a bachelor's degree in engineering science from the US Military Academy, West Point, NY.

Baron is admitted to practice before the state and federal courts of NY, the US Court of Appeals for the Federal Circuit and the Supreme Court of the US. He is also registered to practice before the US Patent and Trademark Office. Baron also served as a US Army Officer with a Regular Army Commission in the Signal Corps, 1970-1975.

Hoffmann & Baron, LLP is a full-service intellectual property law firm specializing in prosecution, counseling, licensing, and litigation of patent, trademark, and copyright-related issues worldwide. The firm's practice also includes unfair competition, trade secrets, licensing, technology-related agreements, and due diligence.

With offices in Syosset, NY and Parsippany, NJ, Hoffmann & Baron, LLP serves clients throughout the US and internationally. Clients include multinational corporations, national research laboratories, universities, entrepreneurial firms, and individuals.

Additionally, the firm provides counseling regarding a variety of other legal issues associated with technology development. The firm's attorneys also counsel clients concerning technology licensing, technology transfer, patent infringement, patent validity, and software protection and licensing.

The firm is also experienced in all phases of intellectual property litigation, opposition, and interference in the US and abroad.

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